

Supporting information

Intercalative and non-intercalative photo-recharge using all-solid-state cells for solar energy conversion and storage

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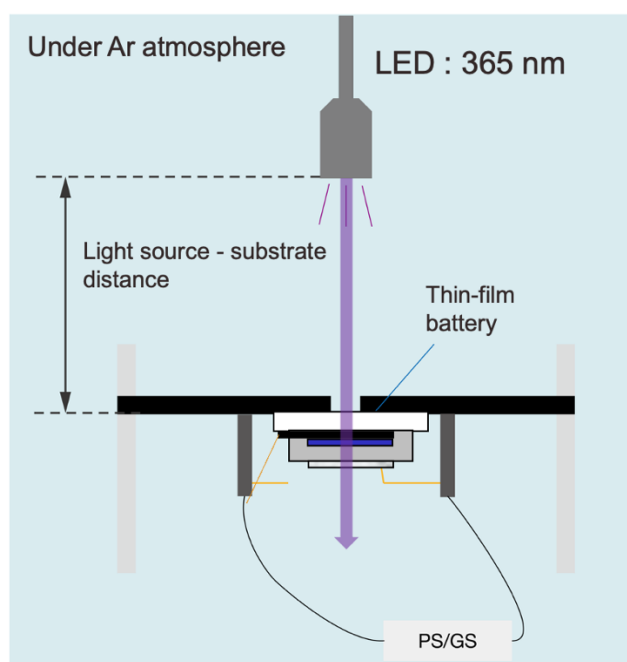


Fig. S1 Scheme of the measurement system for photoelectrochemical measurements.

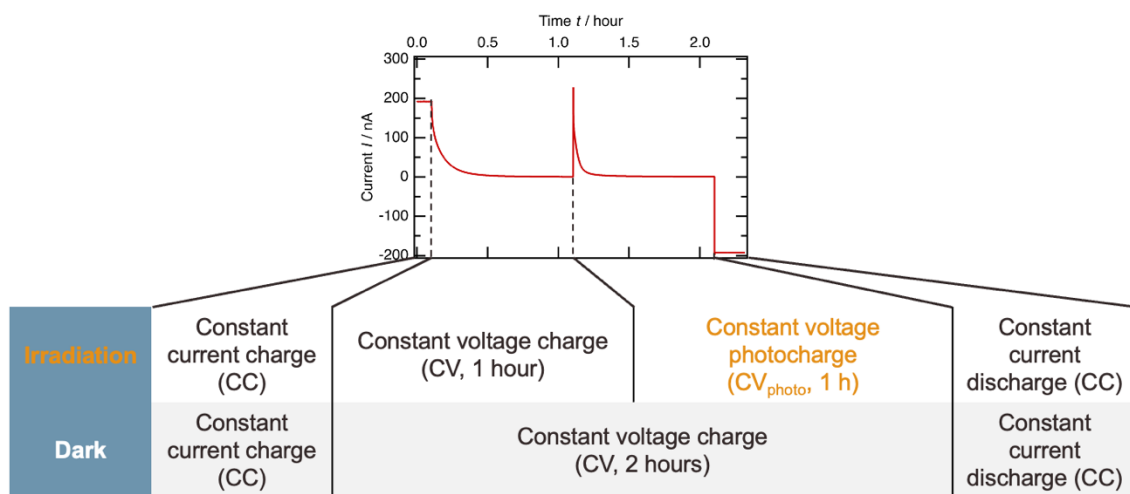


Figure S2 Time variation of current in the constant current-constant voltage-constant voltage under light irradiation (CC-CV-CV_{photo}) / constant current (CC) discharge. The top row of the table shows the CC-CV-CV_{photo} charge/CC discharge method. The bottom row of the table shows the CC-CV charge/CC discharge method.

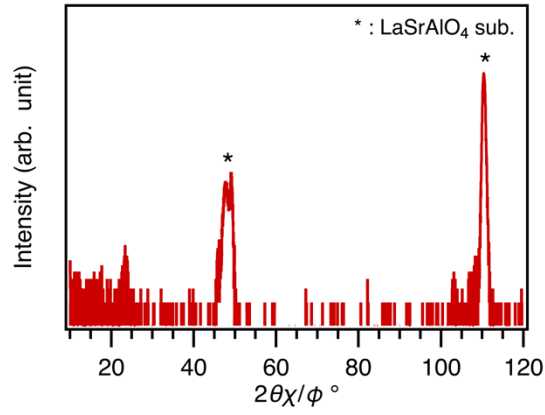


Fig. S3 A X-ray diffraction pattern at in-plane direction of an a-TiO₂:Nb(001)/CaRuO₃(100) films synthesized on LaSrAlO₄(001) substrate.

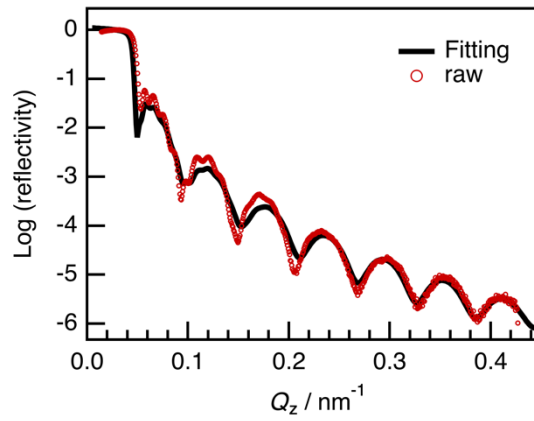


Fig. S4 A X-ray reflection spectra of an a-TiO₂:Nb(001)/CaRuO₃(100) films synthesised on LaSrAlO₄(001) substrate.

Table S1 Refined thickness and roughness of a-TiO₂:Nb and CaRuO₃ films.

Layer	Thickness l/nm	X-ray SLD $\rho / 10^{-4} \text{ nm}^{-2}$	Roughness r/nm
a-TiO ₂ :Nb	10.7	29.845	0.3
CaRuO ₃	40.0	41.194	0.1
LaSrAlO ₄ (substrate)	-	43.938	0.8

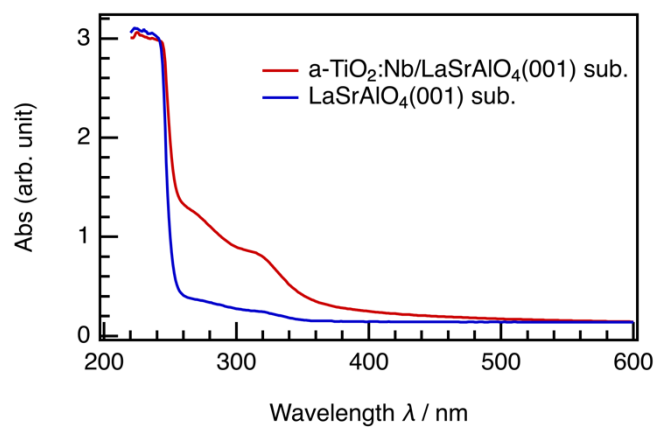


Fig. S5 Absorption spectrums of a-TiO₂:Nb(001)/LaSrAlO₄(001) substrate and LaSrAlO₄(001) substrate.

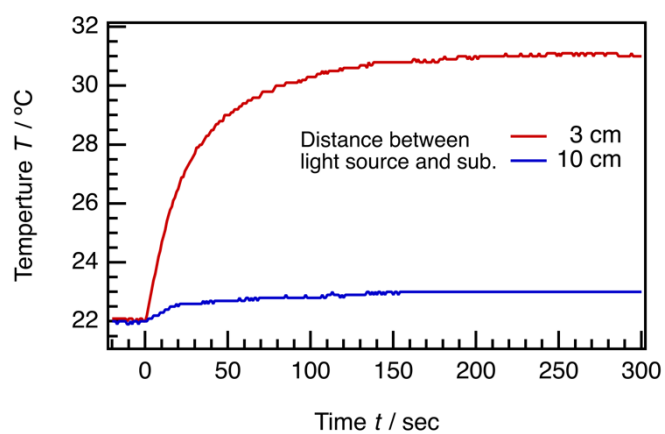


Fig. S6 Temperature change by light irradiation at different distances.